

Room F (Sicily), 2F

Chair: Tatsuro Hiraki (NTT, inc.)

Tu4F

June 30 (Tue), 2026

III-V on Silicon Active Devices I

15:00-16:30

Tu4F-1

15:00-15:15

Optical Chiplet with 0.30-pJ/bit Receiver Using Membrane III-V Photodetector on Si

Yoshiya Shikama^{1,2}, Suguru Yamaoka^{1,2}, Tatsuro Hiraki^{1,2}, Tadashi Minotani^{1,2}, Yohei Saito¹, Takuma Aihara^{1,2}, Yoshiho Maeda^{1,2}, Toru Miura¹, Takuro Fujii^{1,2}, Yuichi Tsujita^{1,2}, Tomonari Sato^{1,2}, Norio Sato^{1,2}, Yuzo Sasaki¹, Shinji Matsuo²

¹NTT Device Innovation Center, ²NTT Device Technology Labs

We demonstrate a four-channel optical receiver chiplet integrating low-capacitance, high-responsivity membrane III-V photodetectors on Si waveguides with a low-power TIA. It achieves 0.51 A/W fiber-to-PD responsivity and 64 Gbit/s PAM4 at 0.30 pJ/bit.

Tu4F-2

15:15-15:30

90-GHz-Bandwidth Membrane EA-DFB Laser on Si with Wide Operating Temperature Range

Hiroshi Kato^{1,2}, Takuma Aihara^{1,2}, Tatsuro Hiraki^{1,2}, Yoshiho Maeda^{1,2}, Takuro Fujii^{1,2}, Tomonari Sato^{1,2}, Shinji Matsuo²

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We demonstrate wide temperature range (20-50°C) operation of an O-band membrane InGaAlAs EA-DFB laser on a silicon photonics platform, achieving clear eye openings at 320-Gbit/s PAM4 using a 90-GHz-bandwidth EAM.

Tu4F-3

Invited

15:30-16:00

Tunable Lasers with InP-Gain Regions on Si Photonic Circuits Using Chip-on-Wafer Bonding

Takuo Hiratani^{1,2,5}, Kento Komatsu^{1,2,5}, Hidenari Fujikata^{1,2}, Naoki Fujiwara^{1,2,5}, Naoko Inoue^{1,2,5}, Takehiko Kikuchi^{1,2,5}, Takuya Mitarai^{1,2,5}, Shun Kimura^{1,2}, Takuya Okimoto^{1,2,5}, Yusuke Sawada^{1,2}, Eiichi Banno^{1,3}, Takashi Matsui³, Takeshi Fujisawa⁴, Nobuhiko Nishiyama^{2,5}, Hideki Yagi^{1,2,5}

¹Sumitomo Electric Industries, Ltd, ²Photonics Electronics Technology Research Association, ³Sumitomo Electric Device Innovations, Inc., ⁴Hosei University, ⁵Institute of Science Tokyo

This paper reviews InP/Si heterogeneously integrated tunable lasers using chip-on-wafer bonding method. The single-chip tunable laser for the C and L bands with the narrow spectral linewidth (< 50 kHz) is demonstrated using this technology.

Tu4F-4

16:00-16:15

High-Efficient and Compact InP/Si Heterogeneously Integrated Coherent-Receiver PICs Using Chip-on-Wafer Bonding

Takuya Mitarai^{1,2}, Takuya Okimoto^{1,2}, Shun Kimura^{1,2}, Takehiko Kikuchi^{1,2}, Naoko Inoue^{1,2}, Naoki Fujiwara^{1,2}, Nobuhiko Nishiyama^{2,3}, Hideki Yagi^{1,2}

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We demonstrate coherent receiver PICs with a Siphotonics-based 90° hybrid and four InGaAs PDs on a 1.2 mm² chip. They exhibit high responsivity (> 0.13 A/W) with small I/Q channel imbalances (60 GHz).

Tu4F-5

16:15-16:30

Monolithic InAs/GaAs Quantum-Dot Laser Diodes on Si for Silicon Photonics Enabled by All-MOCVD Epitaxy: Benchmarking Against GaAs and Ridge-Engineered Functionality

HoSung Kim¹, Honghwi Park², Seungchul Lee², Dae-Myeong Geum², Daehwan Jung³, Won Seok Han²

¹Samsung Advanced Institute of Technology, ²Electronics and Telecommunications Research Institute, ³Korea Institute of Science and Technology

We report an all-MOCVD approach for monolithic InAs/GaAs QDLs on Si(100) and benchmark key metrics with reference devices.